

Amendments to the Claims:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1-17. (Canceled)

18. (Original) A method of manufacturing a carbon nanotube device, characterized by comprising:

an applying step of applying to a surface of a base body a solution containing plural carbon nanotubes having functional groups and a cross-linking agent which prompts a cross-linking reaction with the functional groups;

a cross-linking step of mutually cross-linking the plural carbon nanotubes to construct a network structure through curing of the solution after the application to thereby form a carbon nanotube structure layer having the network structure; and

a patterning step of patterning the carbon nanotube structure layer into a pattern corresponding to a desired device.

19. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the cross-linking agent comprises a not-self-polymerizable cross-linking agent.

20. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the patterning step comprises a step in which the carbon nanotube structure layer in a region on the surface of the base body other than a pattern corresponding to the desired device is subjected to dry etching to remove the carbon nanotube structure layer in the region, whereby the carbon nanotube structure layer is patterned into a pattern corresponding to the desired device.

21. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the patterning step includes:

a resist layer forming step of forming a resist layer above the carbon nanotube structure layer in a region on the surface of the base body having the pattern corresponding to the desired device; and

a removing step of removing the carbon nanotube structure layer exposed in a region other than the region by subjecting a surface of the base body on which the carbon nanotube structure layer and the resist layer are laminated to dry etching.

22. (Original) A method of manufacturing a carbon nanotube device according to claim 21, characterized in that, in the removing step, the surface of the base body on which the carbon nanotube structure layer and the resist layer are laminated is irradiated with an oxygen molecule radical.

23. (Original) A method of manufacturing a carbon nanotube device according to claim 21, characterized in that oxygen molecules are irradiated with ultraviolet rays to generate an oxygen molecule radical, which is used as a radical with which the surface of the base body on which the carbon nanotube structure layer and the resist layer are laminated is irradiated.

24. (Original) A method of manufacturing a carbon nanotube device according to claim 21, characterized in that the patterning step further includes a resist layer peeling-off step of peeling off the resist layer formed in the resist layer forming step subsequent to the removing step.

25. (Original) A method of manufacturing a carbon nanotube device according to claim 21, characterized in that the resist layer comprises a resin layer.

26. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the patterning step comprises a step of patterning the carbon nanotube structure layer into the pattern corresponding to the desired device by selectively irradiating the carbon nanotube structure layer in a region of the surface of the base body other than the region having the pattern corresponding to the desired device with an ion beam of a gas molecule to remove the carbon nanotube structure layer in the region.

27. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the patterning step includes:

a resist layer forming step of forming a resist layer above the carbon nanotube structure layer in a region on the surface of the base body having the pattern corresponding to the desired device; and

a removing step of removing the carbon nanotube structure layer exposed in a region other than the region by bringing a surface of the base body on which the carbon nanotube structure layer and the resist layer are laminated into contact with an etchant.

28. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that:

the functional groups comprise at least one functional group selected from the group consisting of -OH, -COOH, -COOR (where R represents a substituted or unsubstituted hydrocarbon group), -COX (where X represents a halogen atom), -NH₂, and -NCO; and

the cross-linking agent comprises a cross-linking agent capable of prompting a cross-linking reaction with the selected functional groups.

29. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that:

the cross-linking agent comprises at least one cross-linking agent selected from the group consisting of a polyol, a polyamine, a polycarboxylic acid, a polycarboxylate, a polycarboxylic acid halide, a polycarbodiimide, and a polyisocyanate; and

the functional groups comprise functional groups capable of prompting a cross-linking reaction with the selected cross-linking agent.

30. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that:

the functional groups comprise at least one functional group selected from the group consisting of -OH, -COOH, -COOR (where R represents a substituted or unsubstituted hydrocarbon group), -COX (where X represents a halogen atom), -NH₂, and -NCO;

the cross-linking agent comprises at least one cross-linking agent selected from the group consisting of a polyol, a polyamine, a polycarboxylic acid, a polycarboxylate, a polycarboxylic acid halide, a polycarbodiimide, and a polyisocyanate; and

the functional groups and the cross-linking agent are respectively selected for a combination capable of prompting a mutual cross-linking reaction.

31. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the functional groups comprise -COOR (where R represents a substituted or unsubstituted hydrocarbon group).

32. (Original) A method of manufacturing a carbon nanotube device according to claim 31, characterized in that the cross-linking agent comprises a polyol.

33. (Original) A method of manufacturing a carbon nanotube device according to claim 31, characterized in that the cross-linking agent comprises glycerin and/or ethylene glycol.

34. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that the solution further contains a solvent.

35. (Original) A method of manufacturing a carbon nanotube device according to claim 34, characterized in that the cross-linking agent also functions as a solvent.

36. (Original) A method of manufacturing a carbon nanotube device according to claim 18, characterized in that a base body having plasticity or flexibility is used as the base body.

37-48. (Canceled)